

As part of our long-term commitment to continuous improvement, the Industial team worked with NIST\* on original research aimed at identifying a more accurate instrument-based technique for determination of metals.

The target was the development of a methodology to certify direct traceability of assay and associated uncertainty to NIST standardreference materials.

## The result?

## The NIST High-Performance ICP-OES Methodology

\*The National Institute of Standards and Technology

The NIST High-Performance ICP-OES Methodology is the foundation for our A+ Single Element™ Certified Reference Standards

- · 8 independent dillutions of gravimetrically prepared stadard at ICP-OES optimized concentration
- A method-specified internal reference spike for additional control measurements for quantitative
  & statisical analysis
- 800+ measurements in simultaneous comparisons (beyond ISO 17034 requirements
- · 6 hours of unbroken measurement chain
- · Raw data processing using NIST's sophisticated software algorithm
- · Extremely accurate analyte assignments and traceable concentration results
- Expanded uncertainty also directly traceable to NIST\* SRM calibrants generated through further statisical analysis

\*Where available

